

PATENT APPLICATION
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q67844

Takako SUZUKI, et al.

Appln. No.: 10/084,204

Group Art Unit: 1752

Confirmation No.: 6177

Examiner: Unknown

Filed: February 28, 2002

For: POSITIVE PHOTORESIST COMPOSITION AND PROCESS FOR FORMING
RESIST PATTERN USING SAME

REQUEST FOR RECONSIDERATION UNDER 37 C.F.R. § 1.111

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This Request for Reconsideration is submitted in response to the Office Action dated March 27, 2003. A Petition for a three month extension of time is being concurrently filed, making a response due on or before September 29, 2003 (September 27, 2003 being a Saturday). Please consider the remarks as submitted herewith on the accompanying pages.

REMARKS

Claims 1-4 and 6-20 are all the claims pending in the application.